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	Form PTO-1449 (Modified)	<u> </u>	Serial No.:	Unknown	10/805,880		

List of Patents and Publications Statement (Use several sheets if necessary)

Applicant: Uday Shah et al.

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Filing Date: March 22, 2004

REFERENCE DESIGNATION

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Examiner Agara Date Considered 9/15/04

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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